



Correction: Study on photoelectric characteristics of monolayer WS₂ films

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Lin Wang,^a Wenyan Wang,^a Quan Wang,^a Xiaochun Chi,^{*a} Zihui Kang,^a Qiang Zhou,^b Lingyun Pan,^a Hanzhuang Zhang^a and Yinghui Wang^{*a}

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Correction for 'Study on photoelectric characteristics of monolayer WS₂ films' by Lin Wang *et al.*, *RSC Adv.*, 2019, 9, 37195–37200.

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The authors regret that the contact email address for the corresponding authors was incorrect in the original article. The correct email addresses are as shown here.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.



^aFemtosecond Laser Laboratory, Key Laboratory of Physics and Technology for Advanced Batteries (Ministry of Education), College of Physics, Jilin University, Changchun 130012, P. R. China. E-mail: yinghui_wang@jlu.edu.cn; chixc@jlu.edu.cn

^bState Key Laboratory of Superhard Materials, College of Physics, Jilin University, Changchun 130012, P. R. China